

**INFORMATION DISCLOSURE CITATION**  
(Use several sheets if necessary)

Docket Number (Optional) <b>2002DE422</b>	Application Number <b>10/518,315</b>
Applicant(s) <b>Uwe FALK et al.</b>	
Filing Date <b>December 16, 2004</b>	Group Art Unit <b>1794</b>

**U.S. PATENT DOCUMENTS**

*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
		US 3,440,174	4/22/1969	Albrecht			
		US 6,277,476 B1	8/21/2001	Shaw-Klein et al.			
		US 6,358,495 B1	3/19/2002	Nishihama et al.			

**FOREIGN PATENT DOCUMENTS**

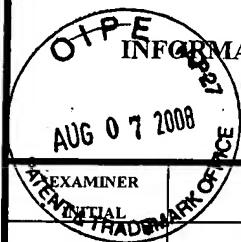
	REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
							YES	NO
		JP 2000-63721 A	2/29/2000	JAPAN				
		JP 2000-203835 A	7/25/2000	JAPAN			✓	
		JP 2000-344509 A	12/12/2000	JAPAN			✓	

**OTHER DOCUMENTS** (Including Author, Title, Date, Pertinent Pages, Etc.)

	Copy of Office action dated June 26, 2008 in co-pending US serial No. 10/451,931. (NOTE: The document cited in the Office Action, US 3,440,174, is not enclosed as it is already of record in the above application.)
	Translation of JPO Office Action issued 2/14/2008 in Japanese Patent Application No. 2002-556121 corresponding to US Serial No. 10/451,931.

EXAMINER	DATE CONSIDERED
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English Language Abstract of JP 2000-203835 A.

English Language Abstract of JP 2000-344509 A.

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